

#12/C  
8/5/03  
Muller

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants: Tews, *et al.* Docket No.: 00P9031US  
Serial No.: 09/714,356 Art Unit: 2813  
Filed: November 16, 2000 Examiner: Chen, Jack S.J.  
For: Nitrogen Implantation Using a Shadow Effect to Control Gate Oxide Thickness

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

AMENDMENT

Dear Sir:

Applicant has received and reviewed the Office Action mailed on July 1, 2003, and respectfully requests reconsideration based on the following remarks.

FAX RECEIVED

JUL 31 2003

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